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List of Documents Cited by Applicant

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First Named Inventor:	Hallahan et al.
Group:	
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U.S. PATENT DOCUMENTS

Examiner Initial	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, where relevant passages or relevant figures appear

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Examiner Initials	Cite No.	Document Number (country code, no., kind code (if known))	Publication Date	Name of Patentee or Applicant	Pages, columns, lines where relevant passages appear	T

OTHER DOCUMENTS

Examiner Initials	Cite No.	Include Author (in CAPITAL LETTERS), Title, Journal, Date, Pertinent Pages, Etc.	T
	1	International Search Report for corresponding PCT Appl. No. PCT/US03/25015 dated April 24, 2004.	
	2	International Preliminary Examination Report for corresponding PCT Appl. No. PCT/US03/25015 dated June 9, 2004.	
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EXAMINER

/Shirley Gembeh/

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5/27/08

*Examiner Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.